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(71) Applicant (*for all designated States except US*):
NANYANG TECHNOLOGICAL UNIVERSITY [SG/
SG]; 50 Nanyang Avenue, Singapore 639798 (SG).

(72) Inventors; and

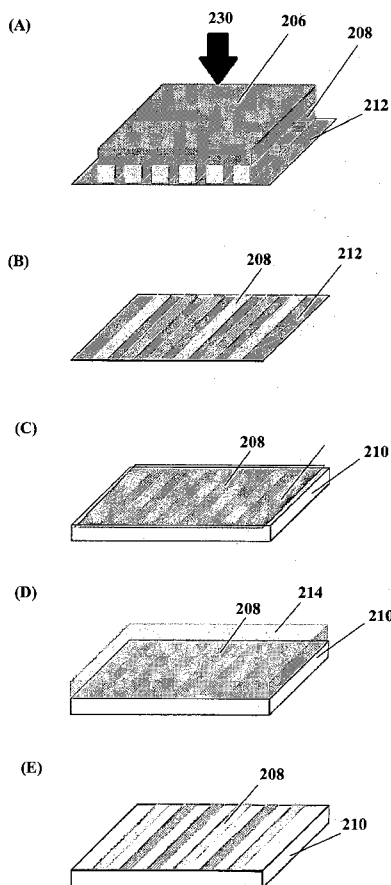
(75) Inventors/Applicants (*for US only*): **YU, Haiyang**
[CN/SG]; Nanyang Technological University, c/o
Nanyang Innovation & Enterprise Office (NIEO), Innova-
tion Centre Blk 1, Unit 100, 16 Nanyang Drive, Singa-
pore 637722 (SG). **TAN, Lay Poh** [MY/SG]; Nanyang
Technological University, c/o Nanyang Innovation & En-
terprise Office (NIEO), Innovation Centre Blk 1, Unit
100, 16 Nanyang Drive, Singapore 637722 (SG).

(74) Agent: **VIERING, JENTSCHURA & PARTNER LLP**;
P.O. Box 1088, Rochor Road, Singapore 911833 (SG).

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(54) Title: METHOD FOR MICROPATTERNING A SUBSTRATE AND A PATTERNED SUBSTRATE FORMED THEREOF

FIGURE 2



(57) Abstract: A method of micropatterning a substrate is provided. The method comprises providing a template substrate having a patterned surface inked with a composition of interest; contacting the patterned surface with an intermediate substrate, thereby transferring the composition to the surface of the intermediate substrate; contacting the surface of the intermediate substrate comprising the composition with the substrate; and removing the intermediate substrate by dissolution using a solvent. A patterned substrate formed using the method, as well as a biosensor comprising the patterned substrate is also provided.



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